

## Characteristics of deep-submicrometer MOSFET and its empirical nonlinear RF model

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Yi-Jen Chan, Chia-Hung Huang, Chung-Chian Weng and Boon-Khim Liew. "Characteristics of deep-submicrometer MOSFET and its empirical nonlinear RF model." 1998 Transactions on Microwave Theory and Techniques 46.5 (May 1998, Part II [T-MTT] (Special Issue on Microwave Circuits on Silicon Substrates)): 611-615.

Si MOSFET's with submicrometer gate length were fabricated and characterized by RF evaluation. Devices with a 0.25  $\mu\text{m}$  gate length demonstrated a  $g_{\text{sub m}}$  of 258 mS/mm, an  $f_{\text{sub T}}$  of 28 GHz, and a minimum noise figure of 1.8 dB at 900 MHz. A nonlinear device model was constructed based on the measured results. Empirical equations are used to represent the nonlinear elements such as  $g_{\text{sub m}}$ ,  $C_{\text{sub gs}}$ ,  $C_{\text{sub gd}}$ ,  $C_{\text{sub ds}}$ , and  $R_{\text{sub out}}$ . These nonlinear elements, together with device parasitics, provide designers with a comprehensive model for using these devices for RF circuits.

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